

Title (en)

Organosilicon compounds and their use in film-forming compositions

Title (de)

Organosiliciumverbindungen und deren Verwendung in filmbildenden Zusammensetzungen

Title (fr)

Composés organosiliciques et leur utilisation dans compositions filmogènes

Publication

EP 0503826 B1 19970702 (EN)

Application

EP 92301837 A 19920304

Priority

GB 9105371 A 19910314

Abstract (en)

[origin: EP0503826A1] Novel neopentasiloxane compounds of the general formula Si[OSiR₂Q]₄ wherein R denotes a monovalent hydrocarbon or halohydrocarbon group and Q denotes a group R or a group comprising a block of at least two oxyalkylene units and having a terminal group containing a reactive hydrogen atom, not more than one Q denoting an R group. The invention also encompasses a film-forming composition comprising a curable polyurethane resin and the neopentasiloxane, and the use of the film-forming compositions to provide breathable (water vapour permeable) coatings on textile fabrics.

IPC 1-7

C07F 7/08; C08G 18/40; D06M 15/564; D06M 15/643; D06M 15/647

IPC 8 full level

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CPC (source: EP KR US)

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Citation (examination)

- CHEMICAL ABSTRACTS, vol. 85, 1976, Columbus, OH (US); A. AKIRA, p. 94, no. 79628x
- CHEMICAL ABSTRACTS, vol. 72, 1970, Columbus, OH (US); V.P. KUZNETSOVA et al., p. 355, no. 31897p

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EP0824102A3; AU2004279969B2; WO2005035674A3

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DOCDB simple family (application)

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